

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

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Listing of Claims:

1. (Currently Amended) An organic electroluminescence (EL) device comprising:
a substrate;
a first electrode on the substrate;
an organic emitting layer on the first electrode; and
a second electrode having a stack of at least one transparent thin film layer on the organic emitting layer;

wherein the transparent thin film layer of the second electrode includes a first layer of a metal, and a second layer of a transparent material; ~~and~~

wherein the first layer and the second layer are stacked alternately; and

wherein the second electrode comprises two or more sets of the first layer and the second layer stack alternately, and each set of the first and second layers is formed directly on an adjacent set of the first and second layers.

2. (Previously Presented) The device as claimed in claim 1, wherein the first electrode is formed of a material selected from the group consisting of ITO, Al, and Ag.
3. (Original) The device as claimed in claim 1, wherein the organic emitting layer includes a stack of a hole injecting layer, a hole transport layer, an emitting layer, an electron transport layer, and an electron injecting layer formed on the first electrode or the second electrode in succession.
4. (Canceled)
5. (Canceled)
6. (Previously Presented) The device as claimed in claim 1, wherein the first layer is formed of a material selected from Ag, Al, Cr, Mo, Au, Pt, Sn, Ln, Mg, Al:Li, Ag:Mg, or

Ag:Li; and the second layer is formed of a material selected from ITO, IZO, TiO_2 , SiO_2 , or Si_3N_4 .

7. (Previously Presented) The device as claimed in claim 1, wherein the transparent thin film layer of the second electrode includes 1 - 100 layers in total.
8. (Previously Presented) The device as claimed in claim 1, further comprising a protection film having at least one transparent thin film layer on the second electrode.
9. (Original) The device as claimed in claim 8, wherein the transparent thin film layer of the protection film includes four layers in total.
10. (Previously Presented) The device as claimed in claim 9, wherein the first layer of the protection film is formed of a material selected from a polymer having a fluorine, stearyl acrylate, lauryl acrylate, 2-phenoxyethyl acrylate, isodecyl acrylate, isooctyl acrylate, isobornyl acrylate, 1,3-butylene glycol acrylate, 1,4-butanediol diacrylate, 1,6-hexanediol diacrylate, ethoxylated bisphenol A diacrylate, propoxylated neophentyl glycol diacrylate, tris(2-hydroxyethyl) isocyanurate triacrylate, or trimethylolpropane triacrylate; the second layer of the protection film is formed of a material selected from SiC, SiO, SiO_2 , or Si_xN_y ;

the third layer of the protection film is formed of a sealant of a silicon compound of an epoxy group or an acryl group; and the fourth layer of the protection film is formed of a material selected from PET, PMMA, or a polymer having a fluorine group.

11. (Currently Amended) An organic EL device comprising:
- a substrate;
 - a first electrode on the substrate;
 - an organic emitting layer on the first electrode;
 - a second electrode having an alternate stack of at least one metal layer and at least a transparent thin film layer on the organic emitting layer; and
 - a protection film having a stack of at least one transparent thin film layer on the second electrode,
- wherein the second electrode comprises a plurality of said alternate stacks of said at least one metal layer and said at least one transparent thin film layer, and each alternate stack is formed directly on an adjacent alternate stack.

12. (Previously Presented) The device as claimed in claim 11, wherein the first electrode is formed of a material selected from the group consisting of ITO, Al, and Ag.

13. (Original) The device as claimed in claim 11, wherein the organic emitting layer includes a stack of a hole injecting layer, a hole transport layer, an emitting layer, an electron transport layer, and an electron injecting layer formed on the first electrode or the second electrode in succession.

14. (Previously Presented) The device as claimed in claim 11, wherein the metal layer of the second electrode is formed of a material selected from Ag, Al, Cr, Mo, Au, Pt, Sn, Ln, Mg, Al:Li, Ag:Mg, or Ag:Li; and the transparent thin film layer is formed of a material selected from ITO, 1ZO, TiO₂, SiO₂, or Si₃N₄.

15. (Original) The device as claimed in claim 11, wherein the second electrode includes 1 - 100 layers in total.

16. (Original) The device as claimed in claim 11, wherein the transparent thin film layer of the protection film includes four layers in total.

17. (Previously Presented) The device as claimed in claim 16, wherein the first layer of the protection film is formed of a material selected from a polymer having a fluorine, stearyl acrylate, lauryl acrylate, 2-phenoxyethyl acrylate, isodecyl acrylate, isooctyl acrylate, iso

bornly acrylate, 1,3-butylene glycol acrylate, 1,4-butanediol diacrylate, 1,6-hexanediol diacrylate, ethoxylated bisphenol A diacrylate, propoxylated neophentyl glycol diacrylate, tris(2-hydroxyethyl) isocyanurate triacrylate, or trimethylolpropane triacrylate; the second layer of the protection film is formed of a material selected from SiC, SiO, SiO₂, or Si_xN_y; the third layer of the protection film is formed of a sealant of a silicon compound of an epoxy group or an acryl group; and the fourth layer of the protection film is formed of a material selected from PET, PMMA, or a polymer having a fluorine group.

18. (Canceled).

19. (Canceled).

20. (Currently Amended) An organic EL device comprising:

a substrate;

a first electrode on the substrate;

an organic emitting layer on the first electrode;

a second electrode having a plurality of alternate stacks, wherein each alternate stack includes at least one metal layer and at least a transparent thin film layer on the organic emitting layer; and

a protection film on the second electrode having a stack of at least one transparent thin film layer,

wherein each alternate stack is formed directly on an adjacent alternate stack.

21. (New) The device as claimed in claim 1, wherein a total number of the first and second layers in the two or more sets is ten.

22. (New) The device as claimed in claim 11, wherein a total number of said at least one metal layer and said at least one transparent thin film layer of the plurality of said alternate stacks is ten.

23. (New) The device as claimed in claim 20, wherein a total number of said at least one metal layer and said at least one transparent thin film layer of the plurality of alternate stacks is ten.